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	Application No.	Applicant(s)
Notice of Allowability	10/644,690 Examiner	STALMANS et al. Art Unit
	Lee, Calvin	2825
Th MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication IGHTS. This application is subject to and MPEP 1308.	plication. If not included not will be mailed in due course. THIS
1. X This communication is responsive to <u>Telephone Interview dated June 22, 2004</u> .		
2. X The allowed claim(s) is/are <u>1-6 and 8-23.</u>		
3. $igotimes$ The drawings filed on <u>19 August 2003</u> are accepted by the	Examiner.	
4.		
Attachm nt(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☑ Interview Summary Paper No./Mail Da 8), 7. ☑ Examiner's Amend	te <u>hereto</u> .

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Docket No: IMEC232.001DV1 STALMANS et al.

OFFICE ACTION

Examiner's Amendment

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312 IN THE CLAIMS:

Claim 1, line 6, after "a light reflector" inserted --wherein the porous silicon layer formed comprises porous silicon parts and columnar conductive parts, said columnar conductive parts forming conductive connections between the substrate and a first region of a semiconductive region-Claim 7 has been canceled.

Claim 8, line 1, replaced "recited in claim 7" with --recited in claim 1--

- 2. Authorization for this examiner's amendment was given in a telephone interview with Richard E. Campbell on June 22, 2004.
- 3. After the conversation, the examiner has found two minor informalities such as: Page 1, line 11, after "April 9, 2001" inserted --and issued as US Patent 6,683,367, -- Page 12 line 31, replaced "is this way" with --in this way-- Page 14 line 13, replaced "a epi-on-porous" with --an epi-on-porous--

Allowable Subject Matter

4. Claims 1-6 and 8-23 are allowed because US 6,194,245 to Tayanaka does not teach, *inter alia*, that a porous silicon layer formed comprises porous silicon parts and columnar conductive parts, and prior to the formation of a porous silicon layer a patterned mask layer is formed on a substrate to thereby define first and second areas.

Any inquiry concerning this communication from the Examiner should be directed to *Calvin Lee* at (571) 272-1896, Monday to Thursday, from 7 to 5 (ET). If attempts to reach the examiner by telephone are unsuccessful, Art Unit 2825's Supervisory Patent Examiner *Matthew Smith* whose telephone number is (571) 272-1907.

Any inquiry relating to the status of this application should be directed to the Group receptionist whose telephone number is (703) 308-0596. The fax phones are (703) 872-9318 for regular communications and (703) 872-9319 for After-Final communications.

MATTHEW SMITH
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800

CL

June 23, 2004